

Supplementary Information

Adsorption-Reduction Synergistic Effect of Mesoporous Fe/SiO₂-NH₂ Hollow Sphere for Removal of Cr(VI) ions

Honglin Yao,^{a†} Qianqian Ding,^{a,b†} Hongjian Zhou,^{a,*} Zhenfu Zhao,^a Gang Liu,^c and Guozhong Wang^{a,*}

^aKey Laboratory of Materials Physics, Centre for Environmental and Energy Nanomaterials, Anhui Key Laboratory of Nanomaterials and Nanotechnology, Institute of Solid State Physics, Chinese Academy of Sciences, Hefei 230031, P.R. China

^b Department of Materials Science and Engineering, University of Science and Technology of China, Hefei, Anhui 230026, P. R. China

^c Institute of Applied Technology, Hefei Institutes of Physical Science, Chinese Academy of Sciences, Hefei 230031, P.R. China

†These authors contributed equally to this work

*Corresponding author: hjzhou@issp.ac.cn (H. Zhou); gzhwang@issp.ac.cn (G. Wang); Tel: 0086-55165595616; Fax: 0086-55165591434.

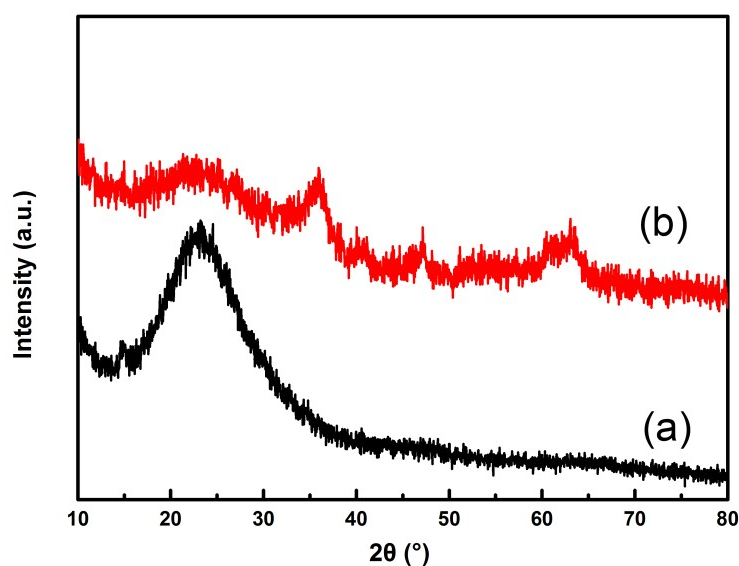


Fig. S1 XRD patterns of (a) silica colloidal spheres and (b) ISHSs.

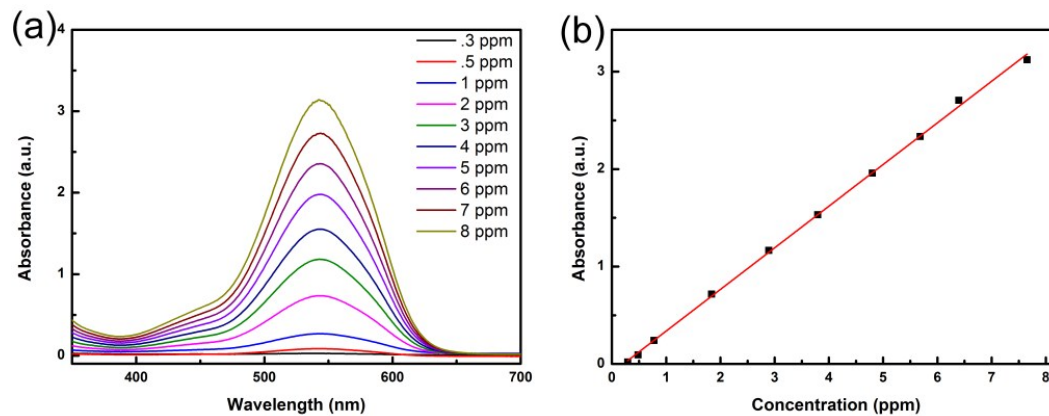


Fig. S2 (a) UV-Vis spectra of standard Cr(VI) solutions with different concentration; (b) linear relationship between Cr(VI) concentration and UV-Vis absorption.

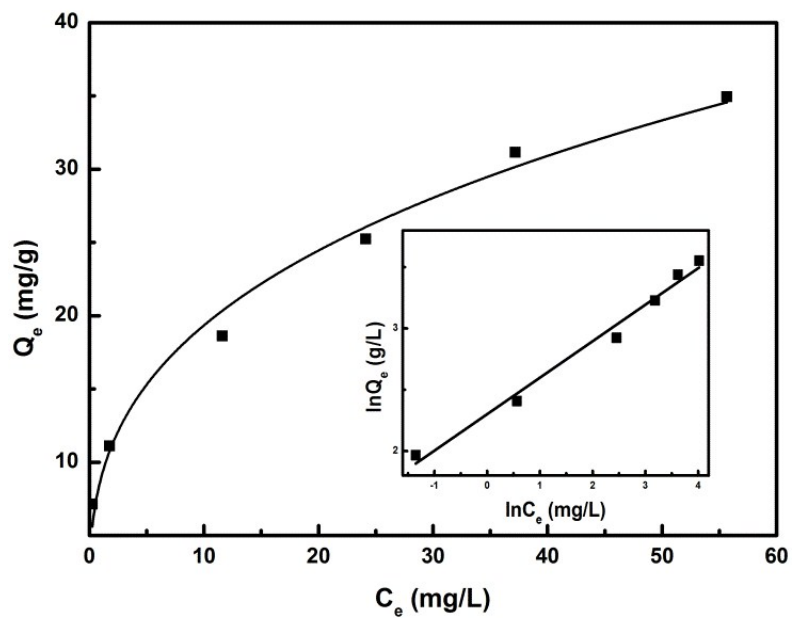


Fig. S3 Adsorption isotherm of Cr(VI) ions on Fe/SiO₂-NH₂ HSs at room temperature.

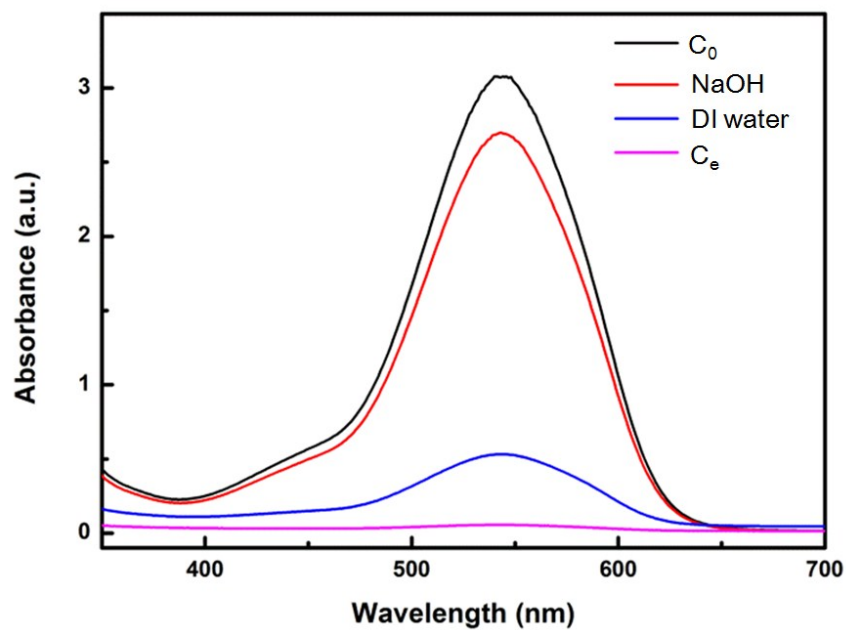


Fig. S4 UV-Vis spectra of the eluted solutions with deionized (DI) water and NaOH solution. C_0 : initial concentration; C_e : equilibrium concentration

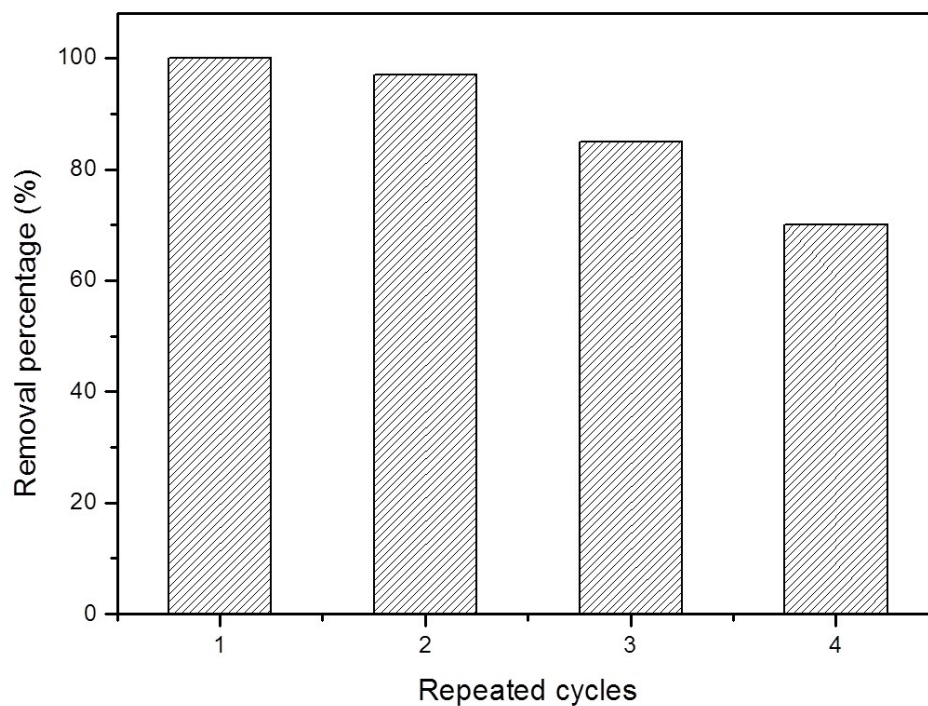


Fig. S5 Adsorbent recyclable of Cr(VI) ions on Fe/SiO₂-NH₂ HSs after four cycles.

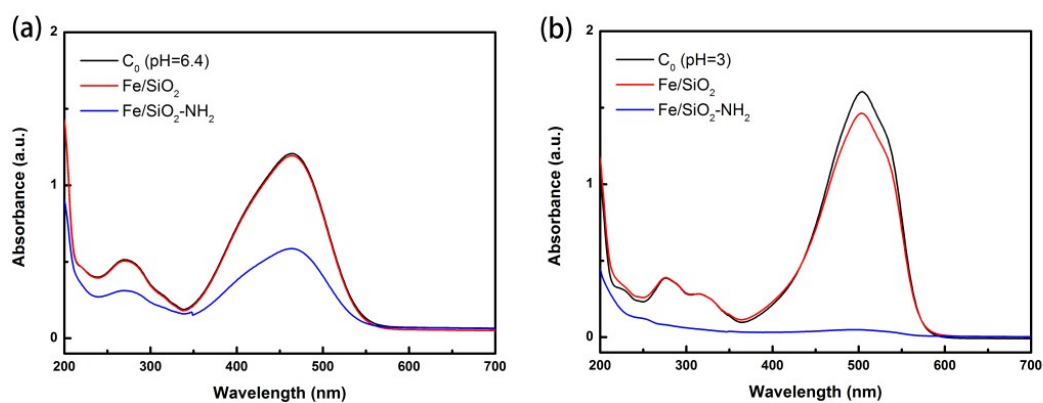


Fig. S6 UV-Vis spectra of MO solutions after being treated by Fe/SiO_2 HSs and Fe/SiO_2-NH_2 HSs at (a) pH = 6.4 and (b) pH = 3. The initial concentration of MO was 20 mg L^{-1} .

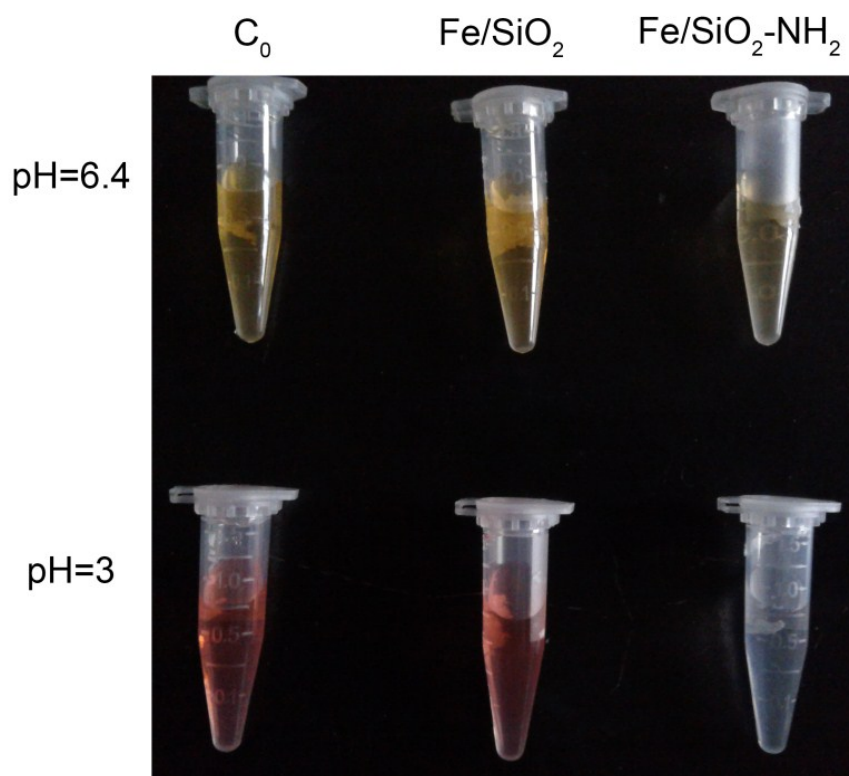


Fig. S7 The digital camera image of MO solutions after being treated by Fe/SiO_2 HSs and Fe/SiO_2-NH_2 HSs.

Table S1 Parameters for Langmuir and Freundlich Models of Cr(VI) adsorption on Fe/SiO₂-NH₂ HSs.

models	equations	parameters		R ²
Langmuir	$Q_e = \frac{bQ_m C_e}{1 + bC_e}$	Q _m (mg·g ⁻¹)	b	0.836
		37.62	0.116	
Freundlich	$Q_e = K_f C_e^{\frac{1}{n}}$	K _f	n	0.985
		8.87	2.95	

Table S2 The maximal removal capacities (q_m) of various adsorbents used for Cr(VI) removal

Classification	Adsorbents	q _m (mg·g ⁻¹)	References
Large size ZVI	Micron Fe	19.2	41
	Scrap iron	1.75	42
nZVI	Bentonite supported nZVI	16.67	43
	Resin supported nZVI	43.1	44
	Bentonite-supported nZVI	7.3	45
	Resin-supported nZVI	28	46
	Entrapment of nZVI in chitosan beads	4	47
	Silica fume supported-nZVI	88	48
	Porous carbon-encapsulated iron	10.07	49
	Fluidized nZVI	10.19	50
	Iron-doped aerogels	55	51
	NZVI/AC	17.4	52
nZVI/K-MMT	8.95	53	
Iron oxide	Magnetic iron-nickel oxide	30	54
	γ-Fe ₂ O ₃ -δ-FeOOH	25.8	55
This work	Fe/SiO ₂ -NH ₂ HSs	37.62	This work

Reference List

41. M. Gheju, A. Lovi and I. Balcu, *J Hazard Mater*, 2008, **153**, 655-662.
42. H. S. Cao and W. X. Zhang, *J Hazard Mater*, 2006, **132**, 213-219.
43. L. N. Shi, Y. M. Lin, X. Zhang and Z. L. Chen, *Chem Eng J*, 2011, **171**, 612-617.

44. F. L. Fu, J. Ma, L. P. Xie, B. Tang, W. J. Han and S. Y. Lin, *J Environ Manage*, 2013, **128**, 822-827.
45. L. N. Shi, X. Zhang and Z. L. Chen, *Water Res*, 2011, **45**, 886-892.
46. S. M. Ponder, J. G. Darab and T. E. Mallouk, *Environ Sci Technol*, 2000, **34**, 2564-2569.
47. T. Y. Liu, L. Zhao, D. S. Sun and X. Tan, *J Hazard Mater*, 2010, **184**, 724-730.
48. Y. C. Li, Z. H. Jin, T. L. Li and S. J. Li, *Water Sci Technol*, 2011, **63**, 2781-2787.
49. L. Z. Zhuang, Q. H. Li, J. S. Chen, B. B. Ma and S. X. Chen, *Chem Eng J*, 2014, **253**, 24-33.
50. S. S. Chen, C. Y. Cheng, C. W. Li, P. H. Chai and Y. M. Chang, *J Hazard Mater*, 2007, 142, 362-367.
51. N. K. Verma, P. Khare and N. Verma, *Green Process Synth*, 2015, 4, 37-46.
52. C. H. Xu, L. J. Zhu, X. H. Wang, S. Lin and Y. M. Chen, *Water Air Soil Poll*, 2014, 225.
53. Y. Y. Zhang, H. Jiang, Y. Zhang and J. F. Xie, *Chem Eng J*, 2013, 229, 412-419.
54. L. S. Wei, G. Yang, R. Wang and W. Ma, *J Hazard Mater*, 2009, 164, 1159-1163.
55. J. Hu, I. M. C. Lo and G. H. Chen, *Sep Purif Technol*, 2007, 58, 76-82.